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Form PTO 1449 U.S. DEPARTMENT OF COMMERCE (Modified) PATENT AND TRADEMARK OFFICE			ATTY DOCKET NO. 247943US-2X APPLICANT		SERIAL NO. 10/760,449			
			APPLICANT		10/700,449			
LIST OF REFERENCES CITED BY APPLICANT								
LIST OF REFERENCES CITED BY AFFEIGANT			Tatsuya KUNIKIYO, et al.		T			
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				January 21, 2004				
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EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE	
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LIST OF RELATED CASES

	D 1 (M 1	Serial or	Filing or	Inventor/
/,	Docket Number	Patent Number	Issue Date	<u>Applicant</u>
MK	PER CLIENT	10/355,068	01/31/03	YAMASHITA et al.
MA	227009US2X	10/232,689	09/03/02	KUNIKIYO et al.
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